Supporting Information

Spontaneous Exfoliation and Tailoring of MoS₂ in Mixed Solvents

Lei Dong, Shan Lin, Liu Yang, Jiajia Zhang, Chao Yang, Dong Yang, Hongbin Lu*

Contents

- 1. Experimental section
- 2. Large-scale preparation of MoS₂ nanosheets
- 3. The effect of H₂O₂ concentration in mixed solvent
- 4. HR-TEM images of the as-prepared MoS₂ nanosheets and nanodots
- 5. Improved yield of spontaneous exfoliation
- 6. Photoluminescence spectra of MoS₂ nanodots
- 7. Crystal defects of MoS₂ nanosheets
- 8. In-site tailoring of MoS₂ nanosheets
- 9. The effect of sonication time
- 10. AFM images of MoS₂ nanosheets with assistance of sonication
- 11. Electrochemical measurement of MoS₂ nanosheets

1. Experimental section

(1) Materials: Pristine MoS₂ (CAS 69860) and graphite flake (CAS 332461) were purchased from Sigma-Aldrich. N-Methyl-2-pyrrolidinone (NMP) and hydrogen peroxide (H₂O₂) were purchased from Sinopharm Chemical Reagent Co. Ltd. All reagents were used without further purification.

Tip sonication were performed with SCS 5200 sonicator from Hangzhou Success Ultrasonic Equipment Co. Ltd, with a nominal power of 500 W. Centrifugation was carried out with a GL-20B centrifuge with a large centrifugal radius (10.6 cm) from Shanghai Anting Scientific Instrument Factory.

(2) Structure characterization: Atomic force microscopy (AFM) measurements were conducted with a Bruker Multimode 8 AFM in tapping mode and the samples were prepared by dropping on freshly cleaved mica substrates. High resolution transmission electron microscopy (HR-TEM) imaging was performed with a JOEL JEM-2100F TEM at an acceleration voltage of 200 kV. The samples were prepared by drop-casting dilute solution of MoS₂ on lacy carbon-coated copper grids. Raman spectra were acquired with a HORIBA JobinYvon XploRa Laser Raman spectrometer with a 532-nm-wavelength laser. The samples were prepared by drop-casting MoS₂ dispersion onto glass substrate. Ultraviolet visible (UV-vis) spectra were obtained with a Perkin-Elmer Lambda 35 UV-Visible spectrophotometer. X-ray photoelectron spectroscopy (XPS) data were obtained using an AXIS UltraDLD system (Shimadzu-Kratos) with Al K_{α} radiation (hv = 1486.6 eV). X-ray diffraction (XRD) were carried out using a PANalytical X'Pert PRO X-ray diffractometer operating at 40 kV and 40 mA with Cu K α radiation (λ = 1.54 Å) at a scanning rate of 5° min⁻¹ and a scanning range from 5 to 90°. The MoS₂ samples used to measure were dried under vacuum. Field emission scanning electron microscopy (FE-SEM) and element mapping images were obtained with a Zeiss Ultra 55 FE-SEM with an energy dispersive spectroscopy mapping system.

- (3) Spontaneous exfoliation: Typically, 20 mg pristine MoS₂ flake was dispersed in 20 mL mixed solvents containing different volume ratios of H₂O₂ (30 wt% aqueous solution) and NMP. The above mixtures (dispersions) were subsequently stirred at 35 °C for 10 hours in 20 mL bottles. At the end, stirring was stopped and the dispersions were cooled down to room temperature naturally. The as-obtained dispersions were used immediately for characterization.
- (4) Ultrasonic-assistant exfoliation: 1.0 and 0.2 g pristine MoS₂ flakes were dispersed in 200 mL mixed solvents containing different volume ratios of H₂O₂ (30 wt%) and NMP (3: 17 and 1: 19 v/v). The dispersions were treated with tip sonication with a nominal power of 500 W for different times (1 h, 2 h, and 5 h). Then the obtained black solution were centrifugated at 5,000 rpm for 30 min. After pouring out the supernatant carefully, the dark black MoS₂ paste was collected.
- (5) Calculation of exfoliation yields: The exfoliated MoS₂ nanosheets were re-dispersed in 500 mL NMP and treated by tip sonication for 30 s. After centrifugation at 500 rpm for 30 min. The upper two-third of the supernatant was collected, repeating this process for 7~9 times until the dispersion completely became colorless. The obtained supernatant and residual precipitate were vacuum-filtered on polytetrafluoroethylene (PTFE) membrane (0.22 μm). After vacuum drying at 50 °C for 10 h, MoS₂ nanosheets (MoS₂-NS, supernatant) and un-exfoliated MoS₂ bulk (MoS₂-B, precipitate) were obtained. The difference between the initial MoS₂ mass and obtained nanosheets (plus mass of the residual unexfoliated particles) was considered as the mass of dissolved MoS₂ and small MoS₂ mass, that is, the final yield equals the mass of exfoliated nanosheets divided by the initial MoS₂ mass.
 (6) MoS₂-graphene composite: MoS₂-graphene composite was prepared using the as-prepared
- MoS₂ nanosheets (by sonication-exfoliation for 1 hour in mixed solvent of H_2O_2 and NMP (3: 17 v/v)) and exfoliated graphene nanosheets with a weight ratio of 4: 1. Graphene

nanosheets were obtained by sonication exfoliation of graphite flake (500 mg) with a tipsonication (with a nominal power of 500 W) for 2 h in 100 mL NMP. After centrifugation at 2,000 rpm for 30 min, the supernatant was collected to obtain graphene dispersion. The graphene dispersion was calibrated by solid content and diluted to 0.1 mg/mL by NMP. Subsequently, 75 mL of graphene dispersion (0.1 mg mL⁻¹) was mixed with 300 mL of the as-prepared MoS₂ dispersion (0.1 mg mL⁻¹ in NMP) and then vacuum-filtered with a PTFE membrane (0.22 μ m) to give the desired MoS₂-graphene composite.

- (7) In-site tailoring: Firstly, the original MoS₂ nanosheets were prepared by traditional ultrasonic-assistant exfoliation, as follows. Pristine MoS₂ (100 mg) was dispersed in NMP (100 ml) and treated by tip-sonic (200 W) for 2 h. The mixture was centrifugated at 1,500 rpm for 30 min to obtain mono-layer nanosheets. Secondly, the supernatant was drop-casted on freshly cleaved mica substrates. After vacuum drying at 50 °C for 10 h, one drop of H₂O₂-NMP mixture with different volume ratio (5:15 or 20:0 v/v) was added onto the mica surface. After standing for 10 min, the mixture was suck out carefully from the edge of mica substrate by filter paper. To remove the rest H₂O₂-NMP mixture, one drop of deionized water was added onto the mica surface and suck out as well. Finally, the in-sited tailoring sheets was obtained by vacuum-drying at 50 °C for 10 h.
- (8) Electrochemical measurement: The electrochemical tests were carried out using twoelectrode cells (2016R size) assembled in an argon-filled glove box. Lithium sheets were used as the counter electrode and reference electrode, and a polypropylene film (Celgard-2300) as a separator. The electrolyte was a LiPF₆ solution (1.0 M) in a mixture of ethylene carbonate and dimethyl carbonate with a volume ratio of 1: 1. The working electrodes were prepared following a slurry coating procedure. The slurry was prepared by mixing an NMP solution of active materials (MoS₂ or MoS₂-graphene composite), carbon black (super P) and binder (polyvinylidene fluoride) with a weight ratio of 70: 15: 15. Then this slurry was spread on current collector (copper foil) and dried at 100 °C for 4 h in air,

followed by vacuum-drying at 100 °C for 12 h and pressing. Galvanostatic charge/discharge cycles were carried out on a NEWARE cell test instrument (Shenzhen Neware Electronic Co., China) between 0.01- 3.00 V at different current densities. 2. Large-scale preparation of MoS₂ nanosheets



Figure S1 Large-scale preparation of MoS_2 nanosheets by spontaneous exfoliation in H_2O_2 -NMP (1:19 v/v) mixed solvent. After mechanically stirring at 35°C for 5 hours, 4g raw MoS_2 was peeled off with yield of 43% (see Figure S5).

3. The effect of H₂O₂ concentration in mixed solvent



Figure S2 Photographs of 1 mg/mL MoS_2 dispersions in different mixed solvents after stirring for 10 hours at 35 °C. The red numbers on caps denote the volume ratios of H_2O_2 to NMP.



Figure S3 The yields of exfoliated and unexfoliated MoS_2 sheets after mechanically stirring for 10 hours in different mixed solvents. The calculation method of the yields is provided in the previous Method and Characterization section. The yields of MoS_2 -NS, MoS_2 -B and MoS_2 -ND are represented by red, blue, and blank column, respectively.

4. HR-TEM images of the as-prepared MoS₂ nanosheets and nanodots



Figure S4 HR-TEM images obtained from spontaneous exfoliation (a) in 20: 0 mixed solvent and ultrasonic-assisted exfoliation (c) in 3: 17 mixed solvent show clearly MoS_2 nanodots. Gaussian fitting (d) suggests a relatively uniform size distribution (2.5 ± 1.0 nm) for MoS_2 nanodots in c. Amplified HR-TEM image (b) of the nanosheets obtained by spontaneous exfoliation in 1: 19 mixed solvent indicates the preservation of MoS_2 lattice in exfoliated nanosheets.

5. Improved yield of spontaneous exfoliation



Figure S5 Improved yields of spontaneous exfoliation of MoS_2 in 1: 19 mixed solvent. When shortening the reaction time to 5 hours, the exfoliation yield increases from 25% of 10 hours reaction time to 43% of 5 hours, implying that the prolonged reaction time practically causes more exfoliated nanosheets to be dissolved. After experiencing another 5 hours of exfoliation in fresh mixed solvent (1: 19), the residual unexfoliated particles were further exfoliated into nanosheets, resulting in an increased exfoliation yield (60.5%).

6. Photoluminescence spectra of MoS₂ nanodots



Figure S6 Photoluminescence spectrum of MoS_2 nanodots (Inset: photoluminescence photo of MoS_2 nanodots, excitation at 365 nm).

Figure S6 shows the photoluminescence spectrum (excitation at 440 nm) of the MoS_2 nanodots, which is the same sample as used in photoluminescence observation excited at 365 nm UV light in the inset. The maximum of luminescence (512 nm) is consistent with the

sonication-exfoliated MoS_2 nanodots.¹ Given that the luminescence property of nanodots is strongly related to their size, the photoluminescence emission around 512 nm would suggest a size of 1.5~3 nm, which is in accordance with the TEM measurements.²



7. Crystal defects of MoS₂ nanosheets

Figure S7 HR-TEM image (a) shows the heterogeneous structure of MoS_2 nanosheets which obtained by spontaneous exfoliation in H_2O_2 -NMP (1: 19 v/v) mixed solvent, in which 1 T regions are enclosed by red lines. Amplified HR-TEM images show the crystal lattices of 1T (b) and 2H (c) phases. Mo 3d (d) and S 2p (e) XPS spectra show the difference between raw MoS_2 and as-prepared MoS_2 nanosheets after Shirley background subtraction. 2H and 1T phases are shown by the deconvoluted spectra and denoted by red and blue lines, respectively.

8. In-site tailoring of MoS₂ nanosheets



Figure S8 Schematic illustration showing the processes of in-site tailoring of MoS_2 nanosheets.



Figure S9 Sheet-tailoring of MoS_2 sheets is confirmed directly by the evolution of AFM images, from original sheets (a) to porous curly patterns (b) to even nanodots (c).



9. The effect of sonication time

Figure S10 The effect of sonication time on the exfoliation yield of MoS_2 particles in 3: 17 mixed solvent. Prolonged sonication time is not always favorable for enhancing the exfoliation yield, instead facilitating the dissolution during the exfoliation and reducing the resulting yield, see the results of sonicating for 5 hours.

10. AFM images of MoS₂ nanosheets with assistance of sonication



Figure S11 MoS₂ nanosheets exfoliated in mixed solvent of H_2O_2 : NMP=1: 19 v/v and solid content of 1 mg/mL with the assistance of sonication (a nominal power of 500 W). The sonication time was 1 hour under ambient condition. The majority of exfoliated nanosheets have irregular shapes and several microns of lateral sizes and 1-3 layers of thickness. Some small pores are also observed clearly. In addition, besides large nanosheets, a large amount of nanodots are present simultaneously, which would arise from tailoring and dissolution of exfoliated nanosheets during the exfoliation.

0.15 1 st 2 nd 0.10 3 rd Current (mA) 0.05 0.00 -0.05 -0.10 -0.15 -0.20 0.0 0.5 1.0 1.5 2.0 2.5 3.0 Voltage (V, vs Li/Li⁺)

11. Electrochemical measurement of MoS₂ nanosheets

Figure S12 CV curves of the first three cycles of MoS₂-graphene composite electrode.



Figure S13 Galvanostatic charge-discharge profiles of the MoS_2 -graphene composite electrode.

Reference

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